

PATENT APPLICATION

10/084204
JC986 US PTO
02/28/02

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of

SUZUKI, Takako, et al.

Attorney Docket No.: Q67844

#4

Divisional of Appln. No.: 09/322,978

Group Art Unit: 1752

D.6.

Confirmation No.: Unknown

Examiner: Unknown

4-24-02

Filed: February 28, 2002

For: POSITIVE PHOTORESIST COMPOSITION AND PROCESS FOR FORMING
RESIST PATTERN USING SAME

INFORMATION DISCLOSURE STATEMENT
UNDER 37 CFR §§ 1.97 and 1.98

Commissioner for Patents
Washington, D.C. 20231

Sir:

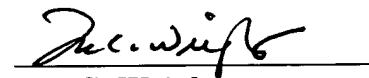
In accordance with the duty of disclosure under 37 CFR §1.56, Applicant
hereby notifies the U.S. Patent and Trademark Office of the documents which are
listed on the attached PTO-1449 form which are all the references of record in
parent application No. 09/322,978. Applicant is not submitting duplicate copies of
these references but requests that they be listed on the face of any patent granted
on the above application. (See 37 CFR §1.98(d)). However, if desired, duplicate
copies will be provided upon request. Copies of any cited copending applications, if
not previously submitted, are being submitted herewith.

The submission of the listed documents is not intended as an admission that
any such document constitutes prior art against the claims of the present

Information Disclosure Statement
Divisional of Appln. No. 09/322,978

application. Applicant does not waive any right to take any action that would be appropriate to antedate or otherwise remove any listed document as a competent reference against the claims of the present application.

Respectfully submitted,


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